The electromagnetic parameters of YBa$_2$Cu$_3$O$_{7-x}$ (YBCO) grain boundary Josephson junctions (JJs) fabricated on four different tilt bicrystal geometries: 12° [001] asymmetric, 24° [001] symmetric, 24° [001] asymmetric, and 45° [100] asymmetric, have been studied. While the Swihart velocity ($\tilde{c}$) is slightly affected by the nature of the barrier and mainly fixed by the junction width, a notable influence of the barrier structure, of the geometry of the bicrystal substrate, on the relative dielectric constant to the barrier thickness ratio ($\varepsilon/\ell$) values has been found. Interesting barrier information can be deduced from the study of the dependence of the junction capacitance on the junction resistance. We have observed that the capacitance values deduced by means of Fiske steps in YBCO 24° [001] symmetric and 45° [100] asymmetric JJs scales with junction resistance in the opposite direction. This result could reveal the presence of a tunnel barrier in the YBCO 45° [100] asymmetric JJs. On the other hand, different capacitance values have been obtained by means of Fiske steps and hysteresis observed in the current-voltage characteristics in 45° [100] asymmetric JJs. An interpretation of this result can be made taking into account the contribution of the depleted YBCO layers close to the crystallographic grain boundary.

DOI: 10.1103/PhysRevB.71.014501  PACS number(s): 74.50.+r

I. INTRODUCTION

A widely used technique for the fabrication of high critical temperature Josephson junctions is the epitaxial growth of YBa$_2$Cu$_3$O$_{7-x}$ (YBCO) thin films on bicrystalline substrates. The first studies carried out on this kind of grain boundary Josephson junctions (JJs) were mainly focused on electrical and structural properties of YBCO thin films deposited on [001] symmetric tilt bicrystals with different misorientation angles.\textsuperscript{1-3} In the following years, because of their critical impact on research and applications of high critical temperature superconductivity, bicrystalline substrates have also been investigated with other kinds of geometries.\textsuperscript{4-7} At this stage, few studies on the structural and transport properties of JJs generated on substrates tilted around a-b planes have been presented.\textsuperscript{8,9} The properties of these geometries have been more extensively studied in JJs fabricated by a biepitaxial technique which has shown to be a good option for the implementation of a reliable technology based on the Josephson effect.\textsuperscript{10-12}

The structure of the barrier depends on many factors like the misorientation angle between the two electrodes, the orientation of the interface plane with respect to crystallographic axes, and the meandering at the barrier, so no prediction of the exact boundary structure is possible. Although some structural analyses on JJs using techniques like transmission electron microscopy\textsuperscript{13} have been performed, the structural and electrical information about the barrier has been mainly derived from the transport parameters: normal resistance ($R_N$) and critical current ($I_C$).

On the other hand, from the position of resonance steps\textsuperscript{14} (Fiske and flux-flow), supporting the idea of the junctions as long parallel resonators for electromagnetic waves, and from the amplitude of the hysteresis observed in the current-voltage ($I-V$) curves of the junctions, it is possible to determine the values of the electromagnetic parameters: the Swihart velocity ($\tilde{c}$) and the relative dielectric constant to the barrier thickness ratio ($\varepsilon/\ell$).\textsuperscript{15,16} and, as a consequence, the value of the barrier capacitance ($C$). Electromagnetic parameters can reveal new insight into the nature of the barrier and are a very useful tool to corroborate the information deduced from transport parameters.

Previously,\textsuperscript{17,18} we presented a study of the electromagnetic parameters of 24° [001] tilt symmetric JJs. For this geometry, we found a new scaling law that sets a constant product $\varepsilon/\ell \times w$ ($w$ is the width of the junction) for samples with the same thickness. A barrier envisaged as a disordered dielectric medium with a high density of superconducting filaments taken into account in an inductive behavior can explain such a result.\textsuperscript{17} Also we studied the evolution of the electromagnetic parameters when the barrier is modified by irradiation with helium at 80 keV and by annealing treatments in oxygen atmosphere.\textsuperscript{18}

In this paper we present a comparative analysis, in terms of electromagnetic parameters, of JJs fabricated using SrTiO$_3$ (STO) bicrystalline substrates of four different tilt geometries. We show that the value of $\tilde{c}$ is mainly fixed by the width of the junction and no big quantitative differences are observed between the four geometries. However, the ratio $\varepsilon/\ell$ is more dependent on the particular structure of the barrier, and so on the kind of bicrystalline substrate used for the fabrication of the JJs. The scaling law previously reported\textsuperscript{17} for YBCO 24° [001] symmetric JJs are not fully verified for 45° [100] asymmetric JJs, pointing to a different
kind of barrier. In this sense, in the final part of the paper we have focused on the comparative analysis of these two geometries to show that interesting information about the particular nature of the barrier can be deduced from the study of the evolution of the junction capacitance with junction resistance.

II. EXPERIMENTAL PROCEDURE

A. Fabrication of the samples

Josephson junctions were fabricated using bicrystalline substrates of STO with different symmetrical and asymmetrical tilt angles around ε-axis and µ-axis: 12° [001] asymmetric, 24° [001] symmetric, 24° [001] asymmetric, and 45° [100] asymmetric JJs. YBCO films 50 nm thick were epitaxially grown in a high pressure (3.4 mbar) pure oxygen dc sputtering system. In the deposition process the substrate temperature was 900 °C. Electrodes showed critical temperatures (Tc) in the range 89.5–91 K, transition widths smaller than 0.2 K, and critical current densities higher than \(10^6\) A/cm² at 77 K. The accurate control of the film growth process with our sputtering system has been previously demonstrated. Films were patterned obtaining junction widths (w) ranging between 2 and 50 µm. A correct control on w is important since it will become a key parameter in our discussion. In this sense, we have estimated that nonuniformity in w associated to the technological etching procedure and depletion effects in the electrode processes introduce an error in w less than 5% for w > 2 µm and in the order of 8% for w=2 µm.

For the electrical measurements the samples have been magnetically shielded and the external magnetic field was applied parallel to the grain boundary plane. The I–V curves for different values of applied magnetic field have been measured using low-noise electronics.

B. Calculus of electromagnetic parameters: \(\bar{c}\) and \(\varepsilon/t\)

We have observed Fiske steps\(^{15}\) in our samples, supporting the idea of the junctions as resonators where the barrier forms the effective dielectric medium. In Fig. 1 we have plotted the I–V curves corresponding to two different geometries where Fiske steps are present. The Fiske steps have been identified because of the dependence of their intensity on the magnetic field applied parallel to the grain boundary plane.\(^{14}\) From the position of the Fiske resonance steps it is possible to determine the velocity \(\bar{c}\) of the resonator using the expression \(V_n = n \phi_0 \bar{c}/2w\), where \(n\) is the resonance number and \(\phi_0\) the magnetic flux quantum.\(^{15}\) Although the two first steps are observed in some I–V curves, we always analyze the resonance \(n = 1\). From the value of \(\bar{c}\) it is possible to determine the \(\varepsilon/t\) ratio, and the C value, using the expression \(\bar{c} = [c_0(t/e\bar{d})^{1/2}]\), where \(c_0\) is the vacuum light velocity and \(d\) the effective magnetic junction length \(d = t + 2\alpha \approx 2\alpha\). In our case, \(\lambda = \lambda_L \coth(\delta/\lambda_L)\), where \(\delta\) is the thickness of the films, since \(\delta\) is smaller than the London penetration depth \(\lambda_L\).\(^{14}\)

The C value can also be determined from the hysteresis in the I–V curves, quantified by the Stewart McCumber parameter \(\beta_c = 2\pi IC\phi_0\).\(^{14}\) I–V curves are hysteretic for \(\beta_c\)

III. RESULTS AND DISCUSSION

A. Electromagnetic parameters

In this section we analyze the electromagnetic parameters calculated for our four different bicrystal configurations. In Fig. 2 we have plotted \(\bar{c}\) versus \(w\) for each kind of JJs fabricated. For all the geometries the value of \(\bar{c}\) increases with \(w\) in the same way as in 24° [001] symmetric JJs.\(^{17,18}\) For a fixed \(w\) and bicrystalline tilt geometry, even in the presence of different \(R_N\) values associated to the barrier, only a small dispersion in the calculated \(\bar{c}\) values can be observed in Fig. 2. Similar dispersion is found if we compare JJs fabricated on different kinds of substrates but with the same \(w\). This

![FIG. 1. (a) I–V characteristic of a [100] tilt 45° asymmetric 20 µm wide junction with an applied magnetic field of 0.56 G. The arrows indicate the Fiske steps corresponding to \(n = 1\) and 2. The I–V curve shows hysteresis in the negative current part. (b) I–V characteristic of [001] tilt 24° symmetric 10 µm wide junction with an applied magnetic field of 0.36 G. The Fiske steps with \(n = 1\) and 2 are observed in the negative part of the curve.]

![FIG. 2. Swinhart velocity vs \(w\) for YBCO JJs fabricated on bicrystalline substrates of different geometries: 12° [001] asymmetric (▲), 24° [001] symmetric (□), 24° [001] asymmetric (●), and 45° [100] asymmetric (▽).]
allows us to corroborate that \( \bar{c} \) is only slightly dependent on the particular properties of the barrier, \( w \) being the main parameter fixing its value.

In a previous published work\(^{17} \) we have deduced that the \( \varepsilon/\ell \times w \) product is approximately constant for a fixed thickness of 24° [001] tilt symmetric JJs. In Fig. 3 we have plotted this product for the same junctions that we have presented in Fig. 2. For \( w > 20 \mu m \), \( I_c \) becomes very large at low temperature and may exceed our current limited low noise electronics. In such a case we have to work with \( I-V \) curves at higher temperatures, which unfortunately implies a decrease of the Fiske steps intensity,\(^{14} \) making the correct assignment of \( V_c \) difficult. We believe that any conclusion for \( w > 20 \mu m \) may be uncertain. In this sense we will carry on our study for JJs with \( w \leq 20 \mu m \). The scaling law previously reported, verified for the 24° [001] tilt symmetric JJs, is not clearly satisfied for the junctions corresponding to the other three substrate geometries. As noted before, the systematic error affecting \( w \) and originated during the technological procedure is small and affects in the same way all our bicrystal geometries. Thus its influence on the deviation from the scaling law is discarded. In particular, the 45° [100] asymmetric JJs show the biggest dispersion, revealing a more notable influence of the nature of the barrier, of the particular bicrystal geometry, on the \( \varepsilon/\ell \) parameter. Although \( \bar{c} \) has a small dependence on the particular JJs (\( R_N \) and kind of substrate), as shown in Fig. 2, \( \varepsilon/\ell \) undergoes a larger influence because of its dependence on \( \bar{c}^2 \). To confirm this aspect, in Table I we present a brief summary of the electromagnetic parameters of junctions of different \( w \) corresponding to 45° [100] asymmetric and 24° [001] symmetric JJs, which gives us a valuable reference because of our previous analysis.\(^{17,18,21} \) As it can be seen in Table I, \( \varepsilon/\ell \) can show more significant variations than \( \bar{c} \) for the same \( w \). In this sense, an analysis of \( \varepsilon/\ell \), of the barrier capacitance, focused to bring information about the microstructure of the barrier and the transport mechanisms, is needed. In the next paragraph we study this point keeping as representative examples the bicrystalline geometries of Table I.

**B. \( \varepsilon/\ell \) ratio: Comparison between 24° [001] symmetric and 45° [100] asymmetric JJs**

In previous works,\(^{22,25} \) a correlation between the capacitance per unit area (A) associated to the barrier (\( C/A \)) and the product \( R_N A \) was observed. Most data fell close to a power law \( (C/A) = (R_N A)^{-1} \). This behavior is common to many high temperature superconducting grain boundary experiments. Indeed, such a correlation was first observed by Moeckly et al.\(^{22} \) for 90° basal plane faced tilt grain boundaries in YBCO and then confirmed in YBCO 24° [001] symmetric JJs on different substrates, and YBCO step-edge junctions.\(^{23} \) This scaling behavior is presented as consistent with the phenomenological filamentary model.\(^{24,25} \) The capacitance is dominated by the contributions from the superconducting regions near the interface which are separated by a short distance of oxygen deficient material. Then, if the number of superconducting filaments increases, \( R_N \) decreases and \( C \) increases.

The \( C/A \) ratio (i.e., the product \( \varepsilon_0 \varepsilon_0 R/\ell \)) can be determined both from Fiske steps resonances and hysteresis of the \( I-V \) curves. However, in the case of 24° [001] symmetrical JJs, the \( C/A \) values have been determined only from the Fiske steps, because in general no hysteresis has been observed even at low temperature. For these junctions, values of \( \beta_C \) ranging between 0.75 and 1.3 have been estimated. Varia-

**TABLE I. Electromagnetic parameters \( (\bar{c} \) and \( \varepsilon/\ell \) for YBCO JJs of different values of \( w \) fabricated on 24° [001] symmetric and 45° [100] asymmetric bicrystalline substrates.**

<table>
<thead>
<tr>
<th>( w ) (( \mu m ))</th>
<th>( R_N ) (( \Omega ))</th>
<th>( \bar{c} \times 10^{-6} ) (m/s)</th>
<th>( \varepsilon/\ell ) (nm(^{-1} ))</th>
<th>( R_N ) (( \Omega ))</th>
<th>( \bar{c} \times 10^{-6} ) (m/s)</th>
<th>( \varepsilon/\ell ) (nm(^{-1} ))</th>
</tr>
</thead>
<tbody>
<tr>
<td>20</td>
<td>4.6</td>
<td>5</td>
<td>4.4</td>
<td>6.8</td>
<td>4</td>
<td>6.8</td>
</tr>
<tr>
<td>20</td>
<td>3.2</td>
<td>5.5</td>
<td>3.6</td>
<td>6.5</td>
<td>5.8</td>
<td>3.3</td>
</tr>
<tr>
<td>10</td>
<td>5.2</td>
<td>3.6</td>
<td>8.5</td>
<td>13.5</td>
<td>2.8</td>
<td>14.1</td>
</tr>
<tr>
<td>10</td>
<td>3.8</td>
<td>4</td>
<td>6.8</td>
<td>11</td>
<td>3.1</td>
<td>11.5</td>
</tr>
<tr>
<td>4</td>
<td>9.5</td>
<td>2.5</td>
<td>17.3</td>
<td>37.1</td>
<td>1.5</td>
<td>48</td>
</tr>
<tr>
<td>4</td>
<td>8.5</td>
<td>2.6</td>
<td>16.1</td>
<td>27</td>
<td>2</td>
<td>27</td>
</tr>
</tbody>
</table>
transport parameters of JJs with this geometry. For instance, we found that transport parameters of 24° symmetric YBCO JJs are not clearly fixed by the resistively shunted junction model (RSJ model). Nevertheless, because of the presence of hysteresis in most of them, we consider that a calculus of the C/A ratio in terms of the \( \beta \) parameter could be also appropriated. Tartè et al. found that the capacitance calculated from the Fiske resonance correlates well with that determined from the hysteresis measurements, but the analysis has mainly been performed on YBCO 45° and 36° [001] symmetrical JJs. In our case, we believe that the observed discrepancy is related to the fact that different regions of the grain boundary contribute to the \( C \) values estimated in the two different methods.

The current steps observed in the \( I-V \) curves are a consequence of an interaction of the Josephson current with resonant modes of the barrier, regarded as a transmission line. The propagation direction of the resonant modes is along the longitudinal direction of the barrier and normal to the Josephson current. It is reasonable to assume that only the most oxygen deficient regions of the barrier, very close to the crystallographic grain boundary, would form the effective dielectric medium supporting the wave propagation. Then, we believe that from Fiske steps, the calculated \( \epsilon/\kappa \) ratio is only related to the region acting as a transmission line. This region would be associated to the crystallographic grain boundary, although it is known that the disorder induced by the grain boundary may also affect the adjacent regions, mainly in the oxygen sublattice. The good agreement between the \( \epsilon/\kappa \) values deduced from current steps and hysteresis in 24° [001] symmetrical JJs might be explained by assuming that the \( \epsilon/\kappa \) ratio in terms of \( C \) and the misorientation angle. The total capacitance \( C \) calculated from hysteresis can be estimated by assuming that it is the serial contribution of these three regions, i.e., \( 1/C_{\text{hysteresis}}=1/C_r+2/C_y (1) \), where we associate

![Diagram](image-url)

**FIG. 4.** Variation of junction capacitance per unit area (\( C/A \)) with junction resistance (\( R_N A \)). In YBCO 24° [001] symmetric JJs, \( C/A \) is calculated from Fiske steps (\( \square \)), and in YBCO 45° [100] asymmetric JJs \( C/A \) is calculated from Fiske steps (\( \triangle \)) and hysteresis of \( I-V \) curves (\( \triangledown \)).

Very interestingly, for the same samples, the \( C/A \) ratios obtained from the \( I-V \) curve hysteresis scale in opposite directions with \( R_N A \). How can the \( C/A \) ratio obtained from hysteresis in the \( I-V \) curves scale in opposite direction with \( R_N A \) than the \( C/A \) ratio deduced from Fiske steps? In general the \( I-V \) characteristics of the 45° [100] asymmetric JJs are affected by the presence of current steps. Then, only in a limited number of cases the \( I-V \) curves are well described by the resistively shunted junction model (RSJ model).
TABLE II. Capacitance per unit area calculated from hysteresis ($C_{\text{hysteresis}}/A$) and Fiske steps ($C_r/A$) observed in the $I–V$ curves. $C_{\text{ld}}/A$ is deduced from $1/C_{\text{hysteresis}}=1/C_r+2/C_{\text{ld}}$. All data correspond to $45^\circ$ [100] asymmetric JJs.

<table>
<thead>
<tr>
<th>$C_{\text{hysteresis}}/A$ (F/µm²)</th>
<th>$C_r/A$ (F/µm²)</th>
<th>$C_{\text{ld}}/A$ (F/µm²)</th>
</tr>
</thead>
<tbody>
<tr>
<td>$9.73 \times 10^{-15}$</td>
<td>$2.32 \times 10^{-13}$</td>
<td>$2.03 \times 10^{-14}$</td>
</tr>
<tr>
<td>$7.87 \times 10^{-15}$</td>
<td>$1.25 \times 10^{-13}$</td>
<td>$1.68 \times 10^{-14}$</td>
</tr>
<tr>
<td>$6.98 \times 10^{-15}$</td>
<td>$3.66 \times 10^{-13}$</td>
<td>$1.42 \times 10^{-14}$</td>
</tr>
<tr>
<td>$5.68 \times 10^{-15}$</td>
<td>$5.91 \times 10^{-14}$</td>
<td>$1.26 \times 10^{-14}$</td>
</tr>
<tr>
<td>$5.38 \times 10^{-15}$</td>
<td>$8.78 \times 10^{-13}$</td>
<td>$1.08 \times 10^{-14}$</td>
</tr>
<tr>
<td>$2.05 \times 10^{-15}$</td>
<td>$4.28 \times 10^{-13}$</td>
<td>$4.32 \times 10^{-14}$</td>
</tr>
</tbody>
</table>

$C_r$ to the value determined from the Fiske resonances, and the value $C_{\text{ld}}$ to each depletion layer situated at both sides of the crystallographic grain boundary, respectively. In Table II we have reported the experimental values $C_{\text{hysteresis}}/A$ and $C_r/A$. $C_{\text{ld}}/A$ is deduced from Eq. (1). Following the band-bending theory,28,29 a theoretical estimation of such a ratio can be made by means of $C_r/A=\varepsilon_0\varepsilon_r/l_d=(\varepsilon_0\varepsilon_r/2l_0)^{1/2}$. The result for $C_{\text{ld}}/A$ is $5.6 \times 10^{-13}$ F/µm² with $\varepsilon=10$, $\varepsilon_0=1$ eV, and $n=4.5 \times 10^{21}$ cm⁻³, values used by Mannhart et al.29 for an estimation of the effective electronic width of YBCO $30^\circ$ [001] tilt symmetric JJs. The parameter values are very conservative because, for example, no data is available for $V_{\text{bd}}$. In this sense, the fact that our calculated data (see Table II) are in the range of 10⁻¹⁴ F/µm² could corroborate a larger $l_d$ value in $45^\circ$ [100] tilt asymmetric JJs than in other bicrystal geometries as we have suggested. We believe that, while in [001] tilt bicrystal geometries with misorientation angles smaller than 30° it is difficult to distinguish the contribution of the adjacent regions,23,27 in $45^\circ$ [100] tilt asymmetric JJs the capacitance values deduced from hysteresis in $I–V$ curves reveal their contribution. This is in accordance with the studies based on atomic-resolution transmission electron microscopy:30 the estimated widths of the nonsuperconducting zones adjacent to the interface increase from 0.2 to 0.9 nm (approximately) for an increase of the misorientation angle from $11^\circ$ to $45^\circ$. Then, changes in the geometry of the bicrystal boundary affect the microstructure of the barrier, so that the depletion layers induced in the adjacent regions of the barrier have to be taken into account for a correct interpretation of the transport and electromagnetic parameters.

IV. SUMMARY

In this paper we have presented a detailed study of electromagnetic parameters of JJs fabricated on bicrystalline substrates with different geometries. While $\bar{c}$ is mainly fixed by $w$ of the junctions, the $\varepsilon/l$ ratio can gain new insight into the nature of the junction barrier. We have previously reported a scaling law ($\varepsilon/l \times w = \text{const}$) for symmetrical $24^\circ$ [001] bicrystalline substrates. However, other geometries like asymmetric $45^\circ$ [100] do not follow this law. In this sense, a more detailed comparative study in terms of the junction capacitance reveals that the nature of the barrier may change from a filamentary model description to a tunnel context. On the other hand, we suggest that current-step resonances are mainly affected by the capacitance of regions very close to the crystallographic grain boundary (thickness t), while the hysteresis in the $I–V$ curve may be also affected by the capacitance of the adjacent depleted layers (thickness $l_d > t$).

ACKNOWLEDGMENTS

The authors would like to thank C. A. de Implantación Iónica from the Universidad Complutense in Madrid for assistance with lithography facilities. Financial support from CICYT Grant No. BMF2001-1419 is acknowledged. This work has been partially supported by the ESF Network “Pi-shift,” the project DG236RIC “NDA,” the TRN “DEQUACS,” and the regional project L.R. N.5 “Proprietà di trasporto e di interfaccia in giunzioni Josephson HTcsu scala submicrometrica.”

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